Narihito Okada

List of Publications by Year in descending order

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| | | 687363 | 580821 |
|----------|----------------|--------------|----------------|
| 52 | 679 | 13 | 25 |
| papers | citations | h-index | g-index |
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| 52 | 52 | 52 | 658 |
| all docs | docs citations | times ranked | citing authors |
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| # | Article | IF | CITATIONS |
|----|--|-----|-----------|
| 1 | Three-dimensional curving of crystal planes in wide bandgap semiconductor wafers visualized using a laboratory X-ray diffractometer. Journal of Crystal Growth, 2022, 583, 126558. | 1.5 | 2 |
| 2 | Investigation of off-cut angle of sapphire for epitaxial lateral overgrowth of AlN and fabrication of high-quality AlN template. Journal of Crystal Growth, 2022, 588, 126640. | 1.5 | 6 |
| 3 | Observation of threading dislocations with a c+m type Burgers vector in HVPE GaN substrates using multi-photon excitation photoluminescence and TEM. Journal of Crystal Growth, 2022, , 126748. | 1.5 | О |
| 4 | Study on higher-energy emission observed locally around V-pits on InGaN/GaN quantum wells grown on moderate-temperature GaN. Journal of Applied Physics, 2021, 130, 053103. | 2.5 | 0 |
| 5 | Deep ultraviolet emission from multiple quantum wells on flat N-polar AlN templates fabricated using periodical pulsed H ₂ etching. Japanese Journal of Applied Physics, 2021, 60, 125502. | 1.5 | 4 |
| 6 | Anisotropic radius of curvature of crystal planes in wide-bandgap semiconductor wafers measured by X-ray diffraction. Japanese Journal of Applied Physics, 2021, 60, 128004. | 1.5 | 2 |
| 7 | Correlation between structural properties and nonradiative recombination behaviors of threading dislocations in freestanding GaN substrates grown by hydride vapor phase epitaxy. CrystEngComm, 2020, 22, 8299-8312. | 2.6 | 13 |
| 8 | Study of dislocations in AlN single-crystal using bright-field synchrotron x-ray topography under a multiple-beam diffraction condition. Applied Physics Letters, 2020, 117, 092102. | 3.3 | 4 |
| 9 | Growth and Characterization of Nitrogenâ€Polar AlGaN/AlN Heterostructure for Highâ€Electronâ€Mobility Transistor. Physica Status Solidi (B): Basic Research, 2020, 257, 1900589. | 1.5 | 13 |
| 10 | Effect of InGaN/GaN Superlattice on Lattice Curvature of GaN Layers Grown on Sapphire Substrates. Physica Status Solidi (B): Basic Research, 2020, 257, 1900586. | 1.5 | 1 |
| 11 | Growth of Nâ€Polar Aluminum Nitride on Vicinal Sapphire Substrates and Aluminum Nitride Bulk Substrates. Physica Status Solidi (B): Basic Research, 2020, 257, 1900588. | 1.5 | 17 |
| 12 | High-quality GaN crystals grown from double-polarity hydride vapor phase epitaxy and single-polarization regrowth. Japanese Journal of Applied Physics, 2019, 58, SC1019. | 1.5 | 0 |
| 13 | Growth of GaN and improvement of lattice curvature using symmetric hexagonal SiO ₂ patterns in HVPE growth. Japanese Journal of Applied Physics, 2019, 58, SC1049. | 1.5 | 6 |
| 14 | Observation of dislocations and their arrays in physical vapor transport-grown AlN single-crystal substrate by synchrotron X-ray topography. Japanese Journal of Applied Physics, 2019, 58, SCCB29. | 1.5 | 10 |
| 15 | Effect of off-angle of stripe patterns on facet stability and embedding in selective-area hydride vapor phase epitaxy growth. Japanese Journal of Applied Physics, 2019, 58, SC1001. | 1.5 | 0 |
| 16 | Separation of effects of InGaN/GaN superlattice on performance of light-emitting diodes using mid-temperature-grown GaN layer. Japanese Journal of Applied Physics, 2018, 57, 062101. | 1.5 | 13 |
| 17 | Spatially Resolved Spectroscopy of Blue and Green InGaN Quantum Wells by Scanning Nearâ€Field Optical Microscopy. Physica Status Solidi (B): Basic Research, 2018, 255, 1700322. | 1.5 | 3 |
| 18 | Potential Barrier Formed Around Dislocations in InGaN Quantum Well Structures by Spot Cathodoluminescence Measurements. Physica Status Solidi (B): Basic Research, 2018, 255, 1700358. | 1.5 | 13 |

| # | Article | IF | Citations |
|----|---|-----|-----------|
| 19 | Impact of thermal treatment on the growth of semipolar AlN on $\langle i \rangle m \langle j \rangle$ -plane sapphire. AIP Advances, 2018, 8, . | 1.3 | 12 |
| 20 | Nanoscopic spectroscopy of potential barriers formed around V-pits in InGaN/GaN multiple quantum wells on moderate temperature GaN pit expansion layers. Journal of Applied Physics, 2018, 124, . | 2.5 | 7 |
| 21 | Mechanism for the formation of nitrogen-filled voids after annealing of GaN on a sapphire substrate. Journal of Applied Physics, 2018, 124, . | 2.5 | 4 |
| 22 | Direct observation of inclined a-type threading dislocation with a-type screw dislocation in GaN. Journal of Applied Physics, 2017, 121, 185101. | 2.5 | 7 |
| 23 | Visualization of dislocation behavior in HVPEâ€grown GaN using facet controlling techniques. Physica Status Solidi (B): Basic Research, 2017, 254, 1600716. | 1.5 | 6 |
| 24 | Bulk GaN substrate with overall dislocation density on the order of 105/cm2 fabricated by hydride vapor phase epitaxy. Journal of Crystal Growth, 2017, 478, 123-128. | 1.5 | 21 |
| 25 | V-shaped pits in HVPE-grown GaN associated with columnar inversion domains originating from foreign particles of α-Si3N4 and graphitic carbon. Micron, 2017, 94, 9-14. | 2.2 | 4 |
| 26 | Alternately doubleâ€sided growth of lowâ€curvature GaN templates on sapphire substrates using hydride vapor phase epitaxy. Physica Status Solidi (B): Basic Research, 2016, 253, 819-823. | 1.5 | 3 |
| 27 | Origin of lattice bowing of freestanding GaN substrates grown by hydride vapor phase epitaxy. Journal of Applied Physics, 2016, 119, . | 2.5 | 16 |
| 28 | Growth of semipolar {20â€"21} GaN and {20â€"2â€"1} GaN for GaN substrate. Physica Status Solidi (B): Basic Research, 2016, 253, 36-45. | 1.5 | 1 |
| 29 | Effect of superlattice on light output power of InGaNâ€based lightâ€emitting diodes fabricated on underlying GaN substrates with different dislocation densities. Physica Status Solidi C: Current Topics in Solid State Physics, 2016, 13, 270-273. | 0.8 | 5 |
| 30 | Thickness and growth condition dependence of crystallinity in semipolar (20–21) GaN films grown on (22–43) patterned sapphire substrates. Physica Status Solidi (B): Basic Research, 2015, 252, 1142-1148. | 1.5 | 5 |
| 31 | Crystalline property analysis of semipolar (20–21) GaN on (22–43) patterned sapphire substrate by Xâ€ray microdiffraction and transmission electron microscopy. Physica Status Solidi (B): Basic Research, 2015, 252, 1149-1154. | 1.5 | 6 |
| 32 | Controlling potential barrier height by changing V-shaped pit size and the effect on optical and electrical properties for InGaN/GaN based light-emitting diodes. Journal of Applied Physics, 2015, 117, . | 2.5 | 40 |
| 33 | WeC-2-1 Transmission electron microscopy study on origin of threading dislocations in GaN layer grown on patterned sapphire substrate. Proceedings of JSME-IIP/ASME-ISPS Joint Conference on Micromechatronics for Information and Precision Equipment IIP/ISPS Joint MIPE, 2015, 2015, WeC-2-1-1- WeC-2-1-3. | 0.0 | O |
| 34 | Fabrication of freestanding {20\$ ar 2 \$1} GaN substrates by HVPE using SiO ₂ masked GaN templates. Physica Status Solidi C: Current Topics in Solid State Physics, 2014, 11, 401-404. | 0.8 | 6 |
| 35 | Epitaxial lateral overgrowth of thick semipolar {11\$ ar 2 \$2} GaN by hydride vapor phase epitaxy. Physica Status Solidi C: Current Topics in Solid State Physics, 2014, 11, 549-552. | 0.8 | 0 |
| 36 | Characterization of semipolar $\{11\$$ ar $2\$2\}$ light-emitting diodes using a hole blocking layer. Physica Status Solidi C: Current Topics in Solid State Physics, 2014, 11, 775-777. | 0.8 | 2 |

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|----|--|-----|-----------|
| 37 | S1660104 Optimal design of the patterned sapphire substrate from viewpoints of light extraction efficiency and crystalline quality of light emitting diodes. The Proceedings of Mechanical Engineering Congress Japan, 2014, 2014, _S1660104S1660104 | | O |
| 38 | I-1-3 Etching of nano-patterned sapphire substrates using chf_3 and BCl_3 inductively coupled plasmas. The Proceedings of the Conference on Information Intelligence and Precision Equipment IIP, 2013, 2013, 8-12. | 0.0 | 0 |
| 39 | Green lightâ€emitting diodes fabricated on semipolar (11–22) GaN on <i>r</i> à€plane patterned sapphire substrate. Physica Status Solidi (A) Applications and Materials Science, 2012, 209, 469-472. | 1.8 | 21 |
| 40 | Growth of {11â€22} GaN on shallowly etched <i>r</i> sâ€plane patterned sapphire substrates. Physica Status Solidi C: Current Topics in Solid State Physics, 2012, 9, 568-571. | 0.8 | 8 |
| 41 | Behavior of misfit dislocations in semipolar InGaN/GaN grown by MOVPE. Physica Status Solidi C: Current Topics in Solid State Physics, 2012, 9, 488-491. | 0.8 | 6 |
| 42 | Growth of semipolar {10\$ ar 1 \$1} GaN from c -plane-like sapphire sidewall of patterned n -plane sapphire substrate. Physica Status Solidi C: Current Topics in Solid State Physics, 2011, 8, 2101-2103. | 0.8 | 15 |
| 43 | Characterization of semipolar (11\$ ar 2 \$2) GaN on c -plane sapphire sidewall of patterned r -plane sapphire substrate without SiO2 mask. Physica Status Solidi C: Current Topics in Solid State Physics, 2010, 7, 2059-2062. | 0.8 | 5 |
| 44 | Evaluation of multipleâ€quantumâ€well structure on InGaN template using (11\$ ar 2 \$2) facet growth and mass transport. Physica Status Solidi C: Current Topics in Solid State Physics, 2010, 7, 2063-2065. | 0.8 | 4 |
| 45 | Growth mechanism of nonpolar m -plane GaN on maskless patterned a -plane sapphire substrate. Physica Status Solidi C: Current Topics in Solid State Physics, 2010, 7, 2066-2068. | 0.8 | 2 |
| 46 | Lightâ€emitting diodes fabricated on nanopatterned sapphire substrates by thermal lithography. Physica Status Solidi C: Current Topics in Solid State Physics, 2010, 7, 2165-2167. | 0.8 | 15 |
| 47 | Growth of <i>m</i> â€GaN layers by epitaxial lateral overgrowth from sapphire sidewalls. Physica Status Solidi (A) Applications and Materials Science, 2009, 206, 1164-1167. | 1.8 | 12 |
| 48 | High-efficiency AlGaN-based UV light-emitting diode on laterally overgrown AlN. Journal of Crystal Growth, 2008, 310, 2326-2329. | 1.5 | 54 |
| 49 | Impact of high-temperature growth by metal-organic vapor phase epitaxy on microstructure of AlN on 6H-SiC substrates. Journal of Crystal Growth, 2008, 310, 2308-2313. | 1.5 | 65 |
| 50 | Dislocations in AlN Epilayers Grown on Sapphire Substrate by High-Temperature Metal-Organic Vapor Phase Epitaxy. Japanese Journal of Applied Physics, 2007, 46, 1458-1462. | 1.5 | 90 |
| 51 | Epitaxial lateral overgrowth of AlN on trench-patterned AlN layers. Journal of Crystal Growth, 2007, 298, 257-260. | 1.5 | 104 |
| 52 | Thermodynamic Aspects of Growth of AlGaN by High-Temperature Metal Organic Vapor Phase Epitaxy. Japanese Journal of Applied Physics, 2006, 45, 2502-2504. | 1.5 | 26 |